

AZ 10XT – run sheet

Merck

[nanyte.com/photorelists/az-10xt](https://www.merck.com/photorelists/az-10xt) · last updated 2026-07-26

Thickness: 4–20 μm

Softbake: 110 °C (95–110 °C) · 2 min · hotplate

Exposure dose: 380 mJ/cm² @ 365 nm

Exposure dose – dose by film thickness · at 365 nm · dense lines, 6 μm film on copper

Film thickness	Dose
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6 μm	455 mJ/cm ²
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Exposure dose – dose by film thickness · at 365 nm · contact holes, 6 μm film on copper

Film thickness	Dose
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6 μm	445 mJ/cm ²
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Develop: Developer AZ 400K · Dilution 1:4 · Time 7 min ·
Method immersion

Hardbake: 90–100 °C